

Notice of References Cited	Application/Control No. 10/720,453	Applicant(s)/Patent Under Reexamination FUFYIGIN, VLADIMIR	
	Examiner David Turocy	Art Unit 1762	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,344,792	09-1994	Sandhu et al.	438/660
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	WO 200284345 A1	10-2002	World Intellect	AHMAD et al.	G02B 06/02
	O	WO 200261467 A	08-2002	World Intellect	WEISBERG et al.	
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	Plasma-enhanced chemical vapor deposition of Ge-Se and Ge-S compound by Blanc et al.
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.